In the Claims:

This listing of claims will replace all prior versions, and listing, of claims in the

application.

Claims 1-50 (Canceled)

51. (Previously amended): A workpiece deposition system for replaceably preventing

deposition on a portion of the a workpiece comprising:

a) a deposition chamber for depositing a film on [[a]] the workpiece;

b) a workpiece support positioned within the deposition chamber for supporting the

workpiece;

c) a replaceable shield of comparable weight as the workpiece, the shield engaging a

portion of the workpiece on the opposite side of the workpiece support and

shielding the engaged portion of the workpiece during deposition thereof to

prevent deposition on the engaged portion of the workpiece;

d) an actuator to move and engage and disengage the shield with the portion of the

workpiece;

e) a shield restraint clamp for holding the shield against the portion of the

workpiece; and

f) a cavity defined by the workpiece support, the workpiece, the shield and the

shield restraint clamp, the cavity adapted to retain a non-reactive gas in the

vicinity of the shielded portion of the workpiece;

wherein the comparable weight of the replaceable shield and the workpiece allows

replacement of the shield in the same way as the replacement of the workpiece[[,]].

52. (Previously amended): An apparatus as in claim 51 in which the shield restraint clamp

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stays close to the workpiece support so that the cavity retaining the non-reactive gas has

no large leak when the shield is engaged with the workpiece.

TEGL-01168US0 SRM/TEGL/01168US0/Amendment.doc 53. (Previously amended): An apparatus as in claim 51 in which the workpiece is a

semiconductor wafer, and the cavity retains the non-reactive in the vicinity of the

circumferencial edge of the semiconductor wafer.

54. (Previously amended): An apparatus as in claim 51 further comprising a shield

restraint press for pressing on the shield restraint clamp so that the shield is

pressing against the portion of the workpiece.

55. (Previously amended): An apparatus as in claim 54 in which the shield restraint press

employs a spring action for pressing on the shield restraint clamp.

56. (Previously amended): An apparatus as in claim 51 further comprising a shield support

for supporting the shield so that the shield and the workpiece are spaced apart when the

shield is disengaged from the workpiece.

57. (Previously amended): An apparatus as in claim 56 further comprising shield aligner

connected to the shield and the shield support for aligning the shield with the shield

support.

58. (Previously amended): An apparatus as in claim 51 further comprising a shield

restraint support for supporting the shield restraint clamp so that the shield and the

shield restraint clamp are spaced apart when the shield is disengaged from the

workpiece.

59. (Previously amended): An apparatus as in claim 51 in which the actuator comprises a

movable shaft connected to the workpiece support.

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